

09/19/01

Class	Subclass
ISSUE CLASSIFICATION	

PATENT NUMBER

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**U.S. UTILITY PATENT APPLICATION**

<p>O.I.P.E.</p> <p>MP</p> <p>SCANNED <u>NS 2</u> Q.A. <u>FW</u></p>	<p>PATENT DATE</p>
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APPLICATION NO. 09/955126	CONT/PRIOR	CLASS 134	SUBCLASS 00	ART UNIT 1746	EXAMINER <del>Wang</del> Chen
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## APPLICANTS

Keum Lee  
Yong Ko  
In Hwang

KORUNKOV

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Method for cleaning damaged layers and polymer residue from semiconductor device

PTO-2040  
12/99

**PREPARED AND APPROVED FOR ISSUE**

ISSUING CLASSIFICATION												
ORIGINAL					CROSS REFERENCE(S)							
CLASS		SUBCLASS			CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL CLASSIFICATION												

☐ Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> a) The term of this patent subsequent to _____ (date) has been disclaimed.  <input type="checkbox"/> b) The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Assistant Examiner) (Date)		NOTICE OF ALLOWANCE MAILED	
	_____ (Primary Examiner) (Date)		ISSUE FEE	
			Amount Due	Date Paid
<input type="checkbox"/> c) The terminal ____months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)		ISSUE BATCH NUMBER	
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Form **PTO-436A**  
(Rev. 10/97)

(LABEL AREA)

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